·	Application No.	Applicant(s)
Nation of Allowskiller	09/904,131	UEDA, TETSUZO
Notice of Allowability	Examiner	Art Unit
	Matthew J. Song	1722
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>9/1/2006</u> .		
2. The allowed claim(s) is/are <u>11,24-26 and 28-34</u> .		
 3. ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have been received. 		
2. Certified copies of the priority documents have been received in Application No.		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached		
1) hereto or 2) to Paper No./Mail Date .		
(b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
Attachment(s)	_	
1. Notice of References Cited (PTO-892)	5. Notice of Informal Pa	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary (Paper No./Mail Date	
3. Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date	7. Examiner's Amendm	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. X Examiner's Stateme	nt of Reasons for Allowance
or biological Material	9.	

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EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Nataniel McQueen on 11/13/2006.

2. The application has been amended as follows:

In line 3 of claim 11, insert "exhibiting bowing in a convex manner" after "wherein the layered substrate comprises sapphire on silicon" and before "and the epitaxial layer".

Allowable Subject Matter

3. The following is an examiner's statement of reasons for allowance: The closest prior art is Molnar et al (US 6,086,673) and Iida et al (JP 53-028374). Molnar et al teaches forming an epitaxial III-V nitride on a layered structure which can include sapphire and silicon. Iida et al teaches a method of forming a silicon on sapphire substrate, wherein silicon is also formed on the backside of the silicon on sapphire substrate to make the substrate substantially flat. The prior does not teach or suggest a layered substrate comprises sapphire on silicon exhibiting bowing in a convex manner.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

Conclusion

4. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Matthew J. Song whose telephone number is 571-272-1468. The examiner

can normally be reached on M-F 9:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Yogendra Gupta can be reached on 571-272-1316. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would

like assistance from a USPTO Customer Service Representative or access to the automated

information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Matthew J Song

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TECHNOLOGY CENTER 1760

MJS

November 13, 2006